

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1103140	(wafer substrate)	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:45
L2	389628	1 and (first near5 (layer material film))	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:45
L3	307273	2 and (second near5 (layer material film))	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:07
L4	67766	3 and (CMP polish\$3)	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:46
L5	25982	4 and ((first second) near5 region)	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:46
L6	25417	5 and surface	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:10
L7	11293	6 and ((first second) near5 thickness)	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:11
L8	5748	7 and polysilicon	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:11
L9	5251	8 and pattern\$4	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:13
L10	4820	9 and (resist mask)	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:14
L11	3150	10 and ((first near8 region) near10 (second near8 region))	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:22
L12	3664	10 and ((low\$3 bottom) near8 (region part surface))	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:23
L13	2461	11 and 12	US-PGPU B; USPAT; USOCR	OR	ON	2007/09/08 08:23

EAST Search History

L14	1612617	(wafer substrate)	FPRS; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/09/08 08:45
L15	122488	14 and (first near5 (layer material film))	FPRS; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/09/08 08:46
L16	3494	15 and (CMP polish\$3)	FPRS; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/09/08 08:46
L17	447	16 and ((first second) near5 region)	FPRS; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/09/08 08:46

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	193285	(wafer substrate).clm.	US-PGPU B	OR	ON	2007/09/08 09:21
L2	130434	(first near5 (layer material film)).clm.	US-PGPU B	OR	ON	2007/09/08 09:21
L3	123333	(second near5 (layer material film)).clm.	US-PGPU B	OR	ON	2007/09/08 09:22
L5	15366	(CMP polish\$3).clm.	US-PGPU B	OR	ON	2007/09/08 09:23
L6	154799	(polysilicon conduct\$3).clm.	US-PGPU B	OR	ON	2007/09/08 09:24
L7	2295	1 and 2 and 3 and 5 and 6	US-PGPU B	OR	ON	2007/09/08 09:24
L9	172381	((first second) near5 (surface region)).clm.	US-PGPU B	OR	ON	2007/09/08 09:25
L10	1584	7 and 9	US-PGPU B	OR	ON	2007/09/08 09:26
L11	97019	((low\$3 bottom) near8 (region part surface)).clm.	US-PGPU B	OR	ON	2007/09/08 09:32
L12	558	10 and 11	US-PGPU B	OR	ON	2007/09/08 09:32
L13	106742	(pattern\$4).clm.	US-PGPU B	OR	ON	2007/09/08 09:41
L14	318	13 and 12	US-PGPU B	OR	ON	2007/09/08 09:41